

# Application to Composition Analysis

## In-line X-ray Metal Film Monitor: MFM 310

### PCM/OTS Application

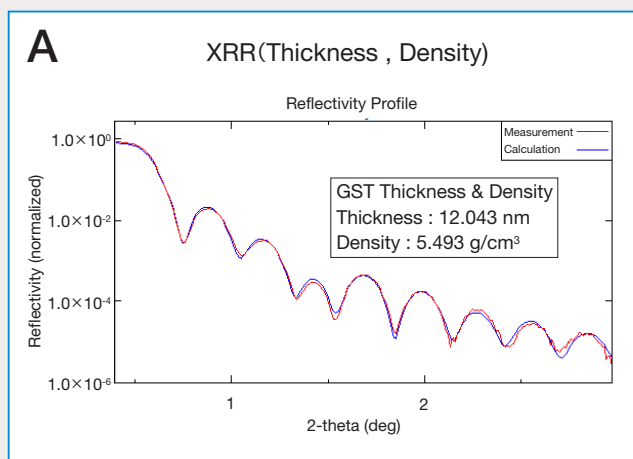
#### XRR/XRF combined analysis

Thickness and Composition can be determined at the same measurement by XRR and XRF combined analysis

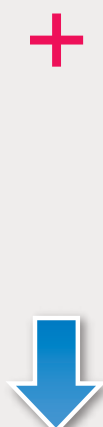
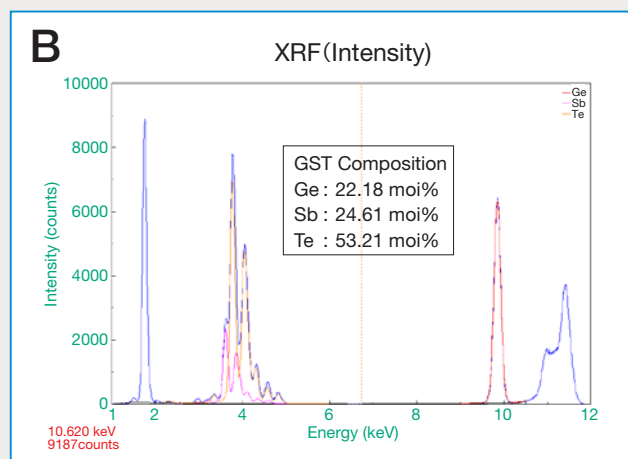
※XRR: X-ray Reflectivity, XRF: X-ray Fluorescent

#### Combined analysis

Step.1 Thickness/ Density : XRR (Analysis result)



Step.2 X-ray intensity : XRF  
(Analysis : \*Calibration curve method)



Thickness and density can be measured by XRR (Fig. A), and the composition ratio of the phase-change material elements can be calculated from XRF measurements (Fig. B). High-precision results are achieved that correspond to changes in film thickness.

### NiSi Application

#### XRD

XRD peak position measurement for NiSi phase identification

